

## INFORMATION DISCLOSURE STATEMENT

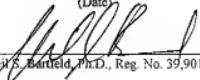
Applicant : Ando et al.  
App. No : 10/572,709  
Filed : March 17, 2006  
For : POSITIVE RESIST COMPOSITION  
AND RESIST LAMINATE FOR LOW-  
ACCELERATION ELECTRON BEAM  
AND METHOD OF PATTERN  
FORMATION  
Examiner : Richard L. Schilling  
Art Unit : 1795

CERTIFICATE OF EFS WEB  
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April 23, 2008

(Date)

  
Neil S. Bartfield, Ph.D., Reg. No. 39,901

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

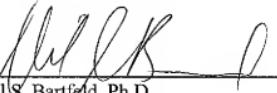
Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing  
5 (five) references to be considered by the Examiner. Also enclosed are 2 (two) foreign patent  
references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the receipt of a first Office  
Action on the merits, and presumably no fee is required. If a first Office Action on the merits  
was mailed before the mailing date of this Statement, the Commissioner is authorized to charge  
the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 4/23/08

By: 

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